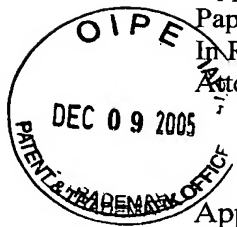


Application No. 10/783,386
Paper Dated December 7, 2005
In Reply to Restriction Requirement of October 7, 2005
Attorney Docket No. 4262-031384



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application No. : 10/783,386 Confirmation No. 6408
Applicants : Larry F. Rhodes et al.
Filed : February 20, 2004
Title : Dissolution Rate Modifiers for Photoresist Compositions
Group Art Unit : 1752
Examiner : Amanda C. Walke
Customer No. : 28289

RESPONSE TO RESTRICTION REQUIREMENT

Mail Stop Amendment
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

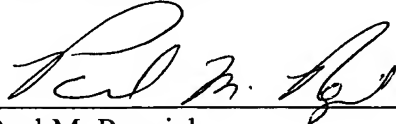
Sir:

In response to the Restriction Requirement dated October 7, 2005, Applicants elect Group I, claims 1-21, for prosecution, without traverse. Applicants elect the structure shown in Fig. 16B, a methoxy methyl ether (MOM) protected HFANB monomer, and described in paragraphs [0074] and [0084] and Synthesis Examples 15 and 16, as the representative species within this group.

An action on the merits is respectfully requested at an early date.

Respectfully submitted,

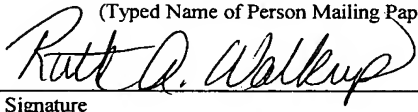
THE WEBB LAW FIRM

By 

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I hereby certify that this correspondence is being deposited with the United States Postal Service as first class mail in an envelope addressed to Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450 on December 7, 2005.

Ruth A. Walkup
(Typed Name of Person Mailing Paper)



Signature

12/07/2005
Date